



Cite this: *Phys. Chem. Chem. Phys.*, 2022, 24, 28295

# Ultrahigh thermoelectric performance of Janus $\alpha$ -STe<sub>2</sub> and $\alpha$ -SeTe<sub>2</sub> monolayers†

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Janus  $\alpha$ -STe<sub>2</sub> and  $\alpha$ -SeTe<sub>2</sub> monolayers are investigated systematically using first-principles calculations combined with semiclassical Boltzmann transport theory. Janus  $\alpha$ -STe<sub>2</sub> and  $\alpha$ -SeTe<sub>2</sub> monolayers are indirect semiconductors with band gaps of 1.20 and 0.96 eV, respectively. It is found that they possess ultrahigh figure of merit (*ZT*) values of 3.9 and 4.4, respectively, at 500 K, much higher than that of the pristine  $\alpha$ -Te monolayer (2.8). The higher *ZT* values originating from Janus structures reduce lattice thermal conductivities remarkably compared with the pristine  $\alpha$ -Te monolayer. The much higher phonon anharmonicity in Janus monolayers leads to significantly lower lattice thermal conductivity. It is also found that electronic thermal conductivity can play an important role in thermoelectric efficiency of materials with quite low lattice thermal conductivity. This work suggests the potential applications of Janus  $\alpha$ -STe<sub>2</sub> and  $\alpha$ -SeTe<sub>2</sub> monolayers as thermoelectric materials and highlights that using a Janus structure is an effective way to enhance thermoelectric performance.

Received 9th August 2022,  
Accepted 28th October 2022

DOI: 10.1039/d2cp03659b

rsc.li/pccp

## Introduction

During the past several decades, thermoelectric (TE) materials have attracted much attention as they can convert waste heat into useful electrical power directly. Generally, a dimensionless figure of merit *ZT* can be used to evaluate the conversion efficiency, which can be expressed as  $ZT = S^2\sigma T/(\kappa_e + \kappa_L)$ , where *S*,  $\sigma$ , *T*,  $\kappa_e$  and  $\kappa_L$  are the Seebeck coefficient, electrical conductivity, absolute temperature, electronic thermal conductivity, and lattice thermal conductivity, respectively. Moreover,  $S^2\sigma$  is the power factor (PF). A high *ZT* value requires a high  $S^2\sigma$  and low thermal conductivity ( $\kappa_e + \kappa_L$ ). Unfortunately, the parameters which determine the *ZT* value are usually interrelated. For instance, *S* and  $\sigma$  generally behave in an opposite manner, greatly complicating the optimization of *ZT* values.<sup>1–3</sup> Usually, for a TE material to show excellent electronic transport properties it should possess a narrow band gap.<sup>4,5</sup> However, it has been reported recently that materials with wide band gaps can also have excellent TE performance due to high motilities and low lattice thermal conductivities.<sup>6–8</sup> Various theoretical and

experimental investigations suggest that reducing the dimensionality can improve the *ZT* value of the TE materials because of the quantum confinement effect and the interface/surface scattering effect.<sup>9–12</sup>

Since the successful exfoliation of graphene in 2004,<sup>13,14</sup> a new field in the study of two-dimensional (2D) materials has opened up. Numerous 2D materials have been investigated theoretically and experimentally for their unique physical and chemical properties.<sup>15–22</sup> Recently, motivated by the successful synthesis of tellurene (2D tellurium),<sup>22</sup> the 2D materials of group VI have attracted much attention, and various 2D materials of Te and Se have been synthesized experimentally.<sup>22–28</sup> It is found that tellurene possesses a high carrier mobility on the order of  $10^3 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$ ,<sup>22</sup> outstanding air stability,<sup>29</sup> and a high on/off ratio on the order of  $10^6$ ,<sup>24</sup> leading to its potential applications in field-effect transistors (FETs), photodetectors, and sensors. Extraordinary electronic transport properties have also been found for few-layer tellurene.<sup>24,30,31</sup> Furthermore, it also shows good potential applications for thermoelectric devices with high thermoelectric performance.<sup>11,32,33</sup>

Recently, Janus 2D materials have become a research hot spot due to the mirror asymmetry in their structure and the resulting distinct properties. Janus transition metal dichalcogenides (TMDs) have been investigated theoretically and experimentally.<sup>34–37</sup> Investigations suggest that Janus monolayers have promising applications in various fields such as electronics, optoelectronics, photocatalysts, and gas sensing.<sup>38–41</sup> In addition, theoretical research studies have found that Janus monolayers usually reduce  $\kappa_L$  obviously compared with the

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† Electronic supplementary information (ESI) available. See DOI: <https://doi.org/10.1039/d2cp03659b>

pristine monolayers, such as Janus MoSSe, ZrSSe, PtSSe, and SnSSe.<sup>42–45</sup> Thus, the Janus structure may possess higher  $ZT$  than the pristine material due to its low thermal conductivity.<sup>46</sup>

In this work, we have investigated the TE properties of Janus  $\alpha$ -STe<sub>2</sub> and  $\alpha$ -SeTe<sub>2</sub> monolayers based on the first-principles calculations. For comparison, the pristine  $\alpha$ -Te monolayer was investigated as well. The dynamic and thermal stability is confirmed using phonon dispersion and the *ab initio* molecular dynamics (AIMD) simulations. It is found that Janus  $\alpha$ -STe<sub>2</sub> and  $\alpha$ -SeTe<sub>2</sub> monolayers possess ultra-high  $ZT$  values up to about 4.0 at 500 K, much higher than the maximum  $ZT$  value of about 2.8 for  $\alpha$ -Te. The ultra-high  $ZT$  originates from the good electronic transport properties and ultra-low thermal conductivity. Janus structures reduce the electronic transport properties as the breaking of inversion symmetry but impair  $\kappa_L$  significantly, leading to the enhancement of  $ZT$ . Furthermore, the importance of electronic thermal conductivity in TE efficiency is highlighted. The physical mechanisms of low  $\kappa_L$  are also investigated. It is found that much higher phonon anharmonicity results in a lower  $\kappa_L$  in Janus monolayers. And the broken inversion symmetry leads to a higher phonon anharmonicity in Janus monolayers, hence a lower  $\kappa_L$ .

## Computational methods

Based on density functional theory (DFT), all the first-principles calculations were performed using the Vienna *ab initio* simulation package (VASP).<sup>47,48</sup> The Perdew–Burke–Ernzerhof (PBE) generalized gradient approximation (GGA) was used as the exchange–correlation functional.<sup>49</sup> For structure optimization, a plane-wave kinetic energy cutoff of 600 eV was chosen, which is much higher than the maximum recommended cutoff to ensure the good convergence of the calculations. During the optimization, a total energy convergence criterion of  $10^{-8}$  eV was chosen, while the force convergence criterion was  $10^{-4}$  eV/Å. A Monkhorst–Pack<sup>50</sup>  $k$ -mesh of  $15 \times 15 \times 1$  was used to sample the Brillouin zone (BZ). The van der Waals (vdW)

correction proposed by Grimme<sup>51</sup> was taken into consideration during the calculations. The effect of spin–orbit coupling (SOC) was also included due to the presence of heavy elements. As the band gap is always underestimated with PBE, HSE06<sup>52</sup> was employed to obtain an accurate electronic band structure and density of states (DOS). To verify the thermal stability, the *ab initio* molecular dynamics (AIMD) simulations controlled using a Nose–Hoover thermostat<sup>53,54</sup> have been performed for 5000 fs with a time step of 1 fs. The electronic transport properties are implemented in the BoltzTraP2 code,<sup>55</sup> where Boltzmann transport theory and relaxation time approximation (RTA) are utilized. The phonon dispersions were obtained using Phonopy.<sup>56</sup> The AlmaBTE code was used to calculate the lattice thermal conductivity by solving the Boltzmann transport equation.<sup>57</sup>

## Results and discussion

The structure of the  $\alpha$ -Te monolayer belongs to the  $\bar{P}3M1$  (164) symmetry group, similar to that of 1T-MoS<sub>2</sub>. The Janus monolayers are built from the pristine  $\alpha$ -Te by replacing Te atoms of the outer layer with S/Se atoms. The optimized structures of three monolayers are shown in Fig. 1, including  $\alpha$ -Te. From the side views, it can be found that the symmetry is broken as two surfaces of the Janus monolayer consist of different chalcogen atoms. The lattice constant  $a$  and buckling height  $d$  of the optimized structures are listed in Table 1, as well as the cohesive energies  $E_c$  per atom for the three materials. Cohesive energy  $E_c$  is defined as:  $E_c = \frac{E_{\text{tot}} - (mE_{\text{Se}} + nE_{\text{Te}})}{m + n}$ , where  $E_{\text{tot}}$  is the total energy of the material studied, while  $E_{\text{Se}}$  and  $E_{\text{Te}}$  are those of isolated Se and Te atoms, respectively. Here  $m$  and  $n$  are the numbers of Se and Te atoms in a primitive cell. The calculated  $E_c$  values are  $-2.38$ ,  $-2.24$ , and  $-2.08$  eV for  $\alpha$ -STe<sub>2</sub>,  $\alpha$ -SeTe<sub>2</sub> and  $\alpha$ -Te monolayers, respectively. This indicates the energetic stability of the Janus monolayers. Moreover, the AIMD simulations also confirm the thermal stability of the three monolayers up to 500 K, as shown in Fig. S1 of the ESI.†

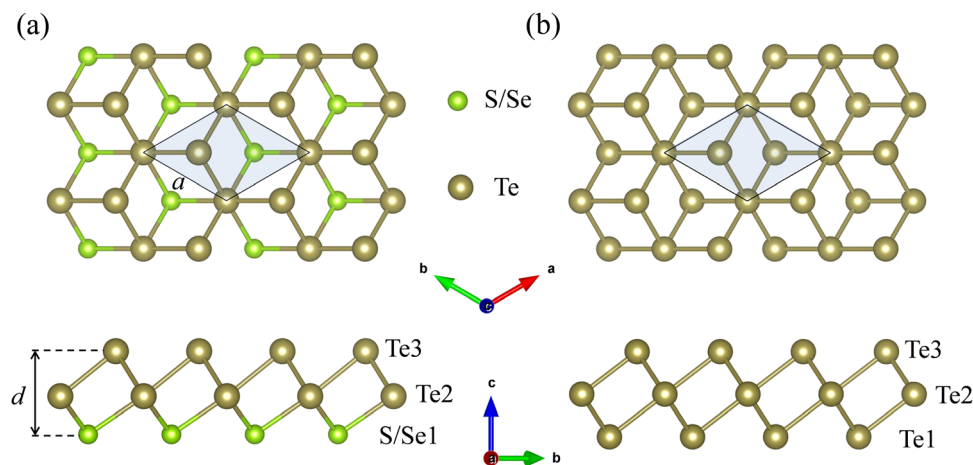


Fig. 1 Side and top views of Janus (a)  $\alpha$ -S/SeTe<sub>2</sub> and (b)  $\alpha$ -Te monolayers. The primitive cells are displayed with blue shading. The symbols S/Se/Te1, Te2, Te3 indicate the atoms located in different layers.

**Table 1** Lattice constant  $a$  and buckling height  $d$  of optimized structures, as well as the cohesive energies  $E_c$  per atom

	$\alpha$ -STe <sub>2</sub>	$\alpha$ -SeTe <sub>2</sub>	$\alpha$ -Te
$a$ (Å)	4.03	4.05	4.15
$d$ (Å)	3.34	3.49	3.67
$E_c$ (eV)	-2.38	-2.24	-2.08

The electronic band structure plays an important role in TE performance. It should be noted that the HSE06 hybrid functional including SOC effects (HSE + SOC) is necessary for obtaining an accurate band structure of the materials containing heavy elements. For instance, the experimental value of the band gap is about 0.33 eV for bulk Te,<sup>58</sup> while the calculated value is 0.31 eV with the HSE + SOC method,<sup>31</sup> very close to the experimental one. For comparison, the PBE, PBE + SOC, and HSE without SOC methods led to values different from the experimental value remarkably.<sup>31</sup> The band gaps calculated with HSE + SOC, HSE, PBE + SOC, and PBE are listed in Table 2. For  $\alpha$ -STe<sub>2</sub>,  $\alpha$ -SeTe<sub>2</sub>, and  $\alpha$ -Te monolayers, the band gaps calculated using HSE + SOC are indirect with values of about 1.22, 0.96, and 0.70 eV, respectively. The data are in good agreement with previous studies.<sup>22,33,59</sup> Furthermore, the band gaps calculated using other methods are significantly different from those calculated using HSE + SOC. For instance, the band gaps calculated using HSE are 1.51, 1.21, and 1.12 eV, significantly larger than those calculated using HSE + SOC. It also verifies that the SOC effect cannot be neglected for the materials containing a heavy Te element. The calculated electronic band structures and partial DOS (PDOS) of the three monolayers with the method of HSE + SOC are shown in Fig. 2, while the band structures calculated using HSE without SOC are shown as well. The conduction band minimum (CBM) is located at the  $\Gamma$  point for all the monolayers. However, the valence band maximum (VBM) is located in the  $\Gamma$ - $M$  line for  $\alpha$ -Te, while they are located in the  $\Gamma$ - $K$  line for  $\alpha$ -STe<sub>2</sub> and  $\alpha$ -SeTe<sub>2</sub>. On the whole, the shapes of band structures are similar, implying that they may have similar values of effective masses overall for three monolayers, as listed in Table 3. However, the VBM of  $\alpha$ -Te is located far from the ones of Janus monolayers, resulting in a large difference in  $m^*$  of holes. Moreover, the valence bands near the Fermi level are relatively flat, facilitating a high PF value, similar to those of Na<sub>x</sub>CoO<sub>2</sub> and FeAs<sub>2</sub>.<sup>60-62</sup> In Fig. 2, it is also found that SOC remarkably affects the shapes of the band structure and the locations of the VBM and CBM. The shapes of curves around the VBM and CBM have a great effect on  $m^*$ . Thus, we choose the data of HSE + SOC to obtain an accurate TE performance. From the PDOS, we

**Table 2** Calculated band gaps with HSE + SOC, HSE, PBE + SOC, and PBE for each monolayer

	HSE + SOC (eV)	HSE (eV)	PBE + SOC (eV)	PBE (eV)
$\alpha$ -STe <sub>2</sub>	1.22	1.51	0.78	1.05
$\alpha$ -SeTe <sub>2</sub>	0.96	1.21	0.58	0.79
$\alpha$ -Te	0.70	1.12	0.44	0.76

can find that the atoms of two outer layers (Te1 and Te3) contribute identically due to the inversion symmetry of the structure in  $\alpha$ -Te, whereas the contributions of two outer layers (S/Se1 and Te3) are not the same in Janus monolayers. The outer S/Se1 atoms contribute much less than the Te2 atoms in the middle layer in Janus monolayers around the CBM, while the contributions of outer Te1/Te3 atoms are nearly the same as those of the Te2 atoms in  $\alpha$ -Te.

The phonon dispersions along high-symmetry lines are investigated, as shown in Fig. 3. The corresponding projected phonon density of states (PhDOS) are also displayed together. There is no negative frequency, indicating the dynamical stability of the three monolayers. In fact, the stabilities of the Janus monolayers were also confirmed in previous studies.<sup>59,63</sup> There are three acoustic phonon branches and six optical phonon branches, as there are three atoms in each primitive cell. The out-of-plane acoustic (ZA), transverse acoustic (TA), and longitudinal acoustic (LA) branches are displayed in red, blue and magenta lines, respectively. Note that the ZA phonon branches are quadratic around the  $\Gamma$  point, while TA and LA branches are linear. It is found that the highest frequencies of  $\alpha$ -STe<sub>2</sub>,  $\alpha$ -SeTe<sub>2</sub>, and  $\alpha$ -Te monolayers are 7.59, 6.23, and 5.73 THz, respectively. This mainly results from the fact that  $\alpha$ -STe<sub>2</sub> has the lowest average atom mass, while that of  $\alpha$ -Te is the heaviest. In  $\alpha$ -Te, the Te atom of the middle layer dominates the PhDOS in the high-frequency range of 3.5–6.0 THz, while the atom of the outer layers contributes significantly in the low-frequency range. Moreover, the contributions of Te1 and Te3 are identical due to the inversion symmetry of the structure. In Janus monolayers, the lighter S/Se atom contributes much more in the high-frequency range. In particular, the S atom is even dominant in the high-frequency range for  $\alpha$ -STe<sub>2</sub>, as it is much lighter than the Te atom. Note that there is a phonon gap between acoustic and optical phonon modes in  $\alpha$ -Te, whereas it does not appear in the two Janus monolayers. Compared to pristine  $\alpha$ -Te, the breaking of the symmetry in the Janus monolayers leads to the breaking of degeneracies and obvious splits between phonon branches, such as at the high-symmetry point  $K$ .

The vibrating patterns of the nine phonon modes around the  $\Gamma$  point are investigated, as shown in Fig. 4. Note that the mode number is given in the ascending order of phonon frequency. Modes 1 to 3 belong to acoustic phonons, while modes 4 to 9 belong to optical phonons. It is found that modes 4, 5, and 8 of Janus monolayers have significant differences between pristine  $\alpha$ -Te monolayers. In  $\alpha$ -Te, the vibrations of these modes have inversion symmetry along the  $c$ -direction, as the structure is symmetrical. However, as in Janus monolayers, the Te atoms of one outer layer are substituted by S/Se atoms, the inversion symmetry of the structure is broken, hence the symmetry of vibration.

By solving the Boltzmann transport equation with the constant relaxation time and single parabolic band (SPB) model,<sup>64</sup> we investigate the electronic transport coefficients of the three monolayers, including the  $S$ ,  $\sigma$ , and PF. Two typical temperatures (300 and 500 K) are selected in the calculation, as shown

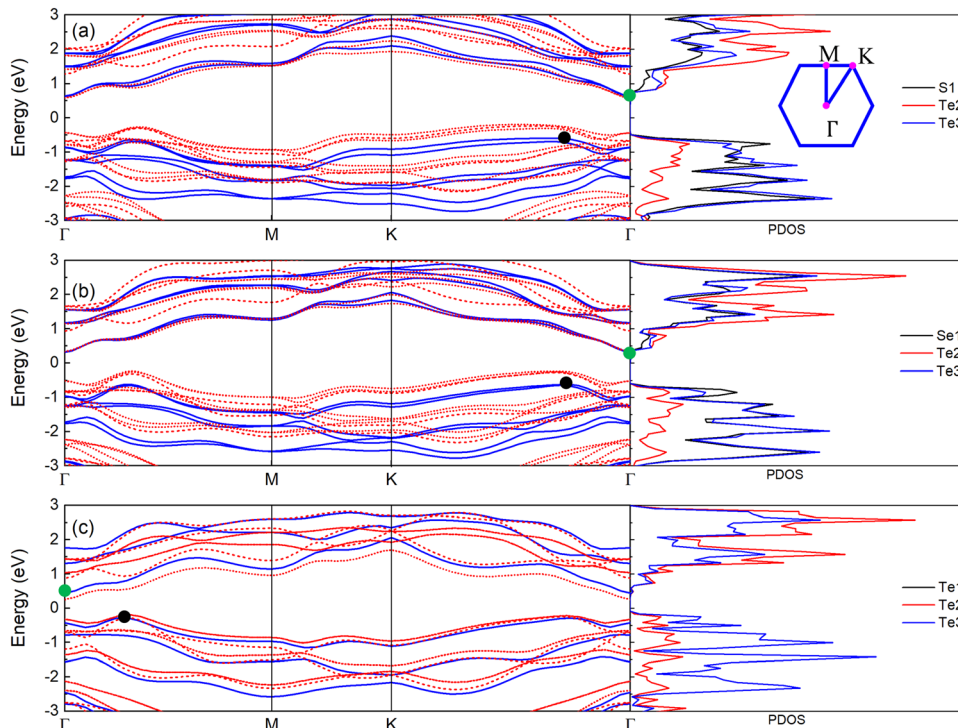


Fig. 2 Electronic band structures of Janus (a)  $\alpha$ -STe<sub>2</sub>, (b)  $\alpha$ -SeTe<sub>2</sub>, and (c) pristine  $\alpha$ -Te monolayers with HSE + SOC, exhibited by blue solid lines. For comparison, the band structures calculated using HSE without SOC are shown in red dashed lines. The partial phonon density of states (PDOS) are also displayed. The inset shows the chosen high-symmetry points. The green and black circles indicate the locations of the CBM and VBM of HSE + SOC for each monolayer. The symbols S/Se/Te1, Te2, and Te3 represent atoms of different layers, as shown in Fig. 1.

Table 3 Elastic constant  $C_{2D}$ , effective mass  $m^*$ , DP constant  $E_i$ , carrier mobility  $\mu$  and the carrier relaxation time  $\tau$  at room temperature.  $m_e$  represents the rest mass of the electron

	Carrier type	$C_{2D}$ (N/m)	$m^*$ ( $m_e$ )	$E_i$ (eV)	$\mu$ ( $\text{cm}^2 \text{V}^{-1} \text{s}^{-1}$ )	$\tau$ (ps)
$\alpha$ -STe <sub>2</sub>	Electron	50.91	0.125	6.06	$1.90 \times 10^3$	0.135
	Hole		0.288	3.92	$8.52 \times 10^2$	0.140
$\alpha$ -SeTe <sub>2</sub>	Electron	46.49	0.114	6.18	$2.00 \times 10^3$	0.130
	Hole		0.288	4.36	$6.30 \times 10^2$	0.103
$\alpha$ -Te	Electron	40.48	0.097	5.86	$2.67 \times 10^3$	0.148
	Hole		0.189	3.58	$1.89 \times 10^3$	0.203

in Fig. 5. On the whole, it is found that the absolute values of Seebeck coefficient  $|S|$  decrease for all the three monolayers with an increase in the carrier concentration  $n$ , as displayed in Fig. 5(a)–(c). Based on the Mahan–Sofo theory,<sup>65</sup>  $|S|$  for 2D materials can be expressed using the following simple model:<sup>12</sup>

$$|S| = \frac{2\pi^3 k_B^2}{3eh^2 n} m^* T, \quad (1)$$

where  $h$ ,  $k_B$ ,  $m^*$ , and  $e$  are the Planck constant, Boltzmann constant, effective mass, and electron charge, respectively. It is found that  $|S|$  is proportional to  $m^*$ , and inversely proportional to  $n$  at a given temperature. From Table 3, it is found that  $m^*$  of the holes is much larger than that of the electrons, due to the smaller band curvature around the VBM than that around the CBM as shown in Fig. 2. Thus,  $|S|$  of p-type doping is bigger than that of n-type doping for three monolayers.  $|S|$  values are

close to each other among the three monolayers. For instance, at 500 K and  $10^{13} \text{ cm}^{-2}$  of  $n$ ,  $|S|$  values are 323, 331, and  $312 \mu\text{V K}^{-1}$  for  $\alpha$ -STe<sub>2</sub>,  $\alpha$ -SeTe<sub>2</sub>, and  $\alpha$ -Te monolayers, respectively. Furthermore,  $|S|$  at 500 K is higher than that at 300 K, as it is proportional to  $T$  based on eqn (1).

The carrier relaxation time  $\tau$  is required to obtain  $\sigma$ .<sup>55</sup> From the conventional Boltzmann transport theory, electrical conductivity  $\sigma$  is proportional to the carrier relaxation time  $\tau$ , which can be expressed as  $\tau = \frac{m^* \mu}{e}$ , where  $\mu$  is the carrier mobility. By using the deformation potential (DP) theory,  $\mu$  of 2D materials can be written as:<sup>66</sup>

$$\mu = \frac{e\hbar^3 C_{2D}}{k_B T m^* m_d E_i^2}, \quad (2)$$

where  $\hbar$  and  $C_{2D}$  are the reduced Planck constant and 2D elastic constant, respectively.  $m_d$  is the average effective mass calculated using  $m_d = \sqrt{m_x^* m_y^*}$ . However, for in-plane isotropic materials here,  $m_x^* = m_y^*$ .  $E_i = \frac{\Delta E_{\text{edge}}}{\Delta a/a}$  is the deformation potential constant, where  $\Delta E_{\text{edge}}$  is the shift in the band energy of the VBM/CBM under small compression or expansion, and  $\Delta a$  is the change in the lattice parameter relative to the equilibrium lattice parameter  $a$ . The vacuum energy level correction is considered in the calculations. The calculated data are listed in Table 3. From the  $\alpha$ -STe<sub>2</sub> to  $\alpha$ -Te monolayer,  $C_{2D}$  becomes smaller, as the S–Te bond is the strongest and the

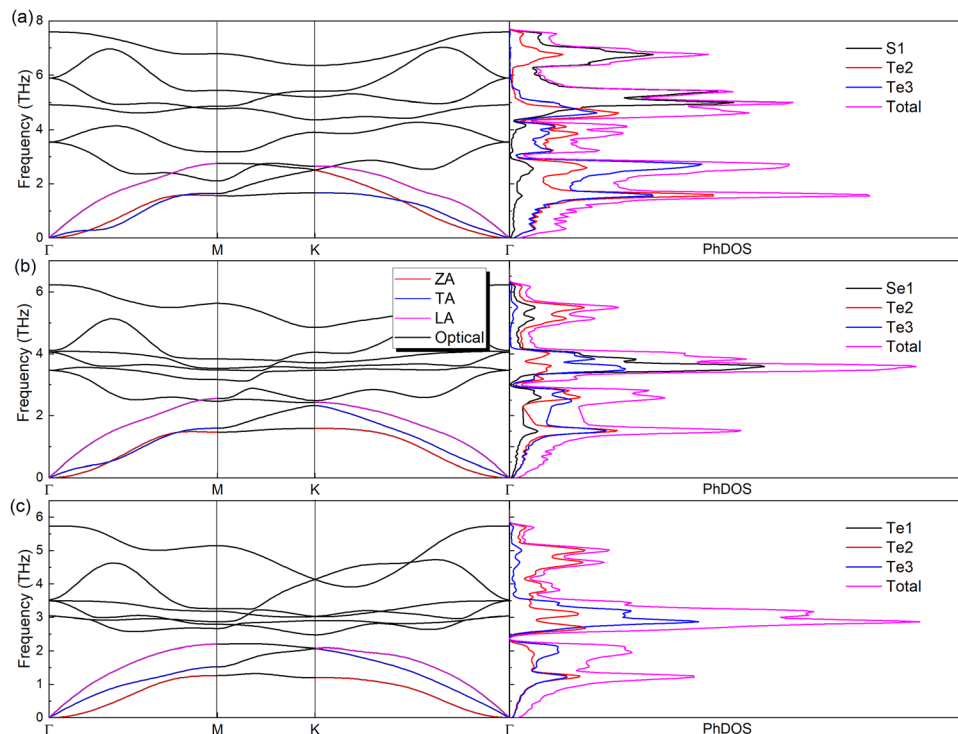


Fig. 3 Phonon dispersions and projected PhDOS of (a)  $\alpha$ - $\text{STE}_2$ , (b)  $\alpha$ - $\text{SeTe}_2$ , and (c)  $\alpha$ - $\text{Te}$  monolayers. Red, blue, and magenta lines indicate ZA, TA, and LA phonon branches, respectively.

Te-Te bond is the weakest. The carrier relaxation times  $\tau$  of electrons and holes for the three monolayers are close to each other, in the range of 0.1–0.2 ps.

The electrical conductivity  $\sigma$  of the three monolayers is obtained through the calculated carrier relaxation time  $\tau$ , as shown in Fig. 4(d)–(f). It is found that  $\sigma$  increases with the increasing carrier concentration  $n$ , and decreases with

temperature  $T$ . The curves of 300 K are higher than the ones of 500 K. On the whole,  $\sigma$  of n-type doping is higher than that of p-type doping at the same  $n$  and  $T$ . The dependencies of  $\sigma$  can be interpreted using a simple model  $\sigma = ne\mu$ .<sup>67</sup> It correlates positively with  $n$ , contrary to the situation of  $S$ . Furthermore,  $\sigma$  is inversely proportional to  $m^*$  and  $T$  based on eqn (2). As  $m^*$  of an electron is smaller than that of a hole for each monolayer,  $\sigma$  of n-type doping is higher.

Then, based on  $S$  and  $\sigma$ , the power factor PF as a function of carrier concentration  $n$  is calculated and shown in Fig. 4(g)–(i). A high value of PF needs a large  $S$  and  $\sigma$  simultaneously, as  $\text{PF} = S^2\sigma$ . PF has a maximum value at an optimum  $n$ , due to the decreasing function of  $S$  and the increasing function of  $\sigma$ . In all cases, the PF value of n-type and p-type doping increases first and then decreases with increasing  $n$ . It is found that PF values at 300 K are generally higher than the values at 500 K for n-type and p-type doping. Moreover, the PF values of n-type doping are much lower than those of p-type doping for the three monolayers. The maximum values of PF are 0.035, 0.034, and 0.055  $\text{W mK}^{-2}$  for p-type doped  $\alpha$ - $\text{STE}_2$ ,  $\alpha$ - $\text{SeTe}_2$ , and  $\alpha$ - $\text{Te}$  monolayers, respectively, at 300 K. At 500 K, the maximum values are 0.036, 0.028, and 0.040  $\text{W mK}^{-2}$ , respectively. The high values of PF are comparable with those of many TE materials, such as 2D SnSe and Penta-silicene,<sup>12,68</sup> indicating they may show high TE performance as well.

A high value of  $ZT$  also needs a minimum thermal conductivity, including electronic thermal conductivity  $\kappa_e$  and lattice thermal conductivity  $\kappa_L$ .  $\kappa_e$  can be calculated through the Wiedemann–Franz law:  $\kappa_e = L\sigma T$ , where  $L$  is the Lorenz number.<sup>69</sup>

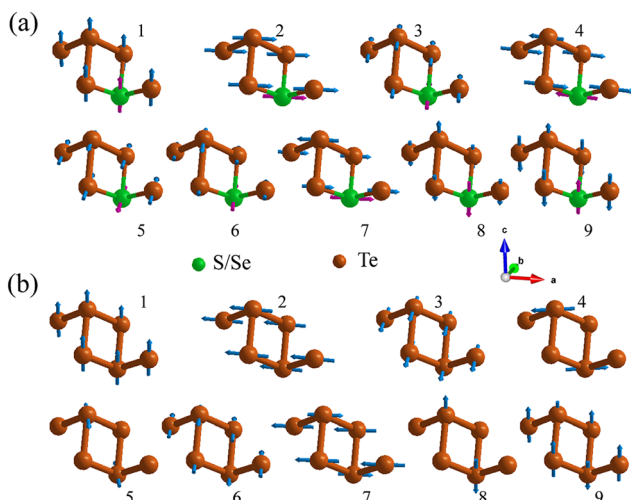


Fig. 4 Vibration patterns of the nine phonon modes around the  $\Gamma$  point for Janus monolayers (a) and pristine  $\alpha$ - $\text{Te}$  monolayers (b). The arrows show the vibration directions of each atom. The number is given in the ascending order of phonon frequency for each mode.

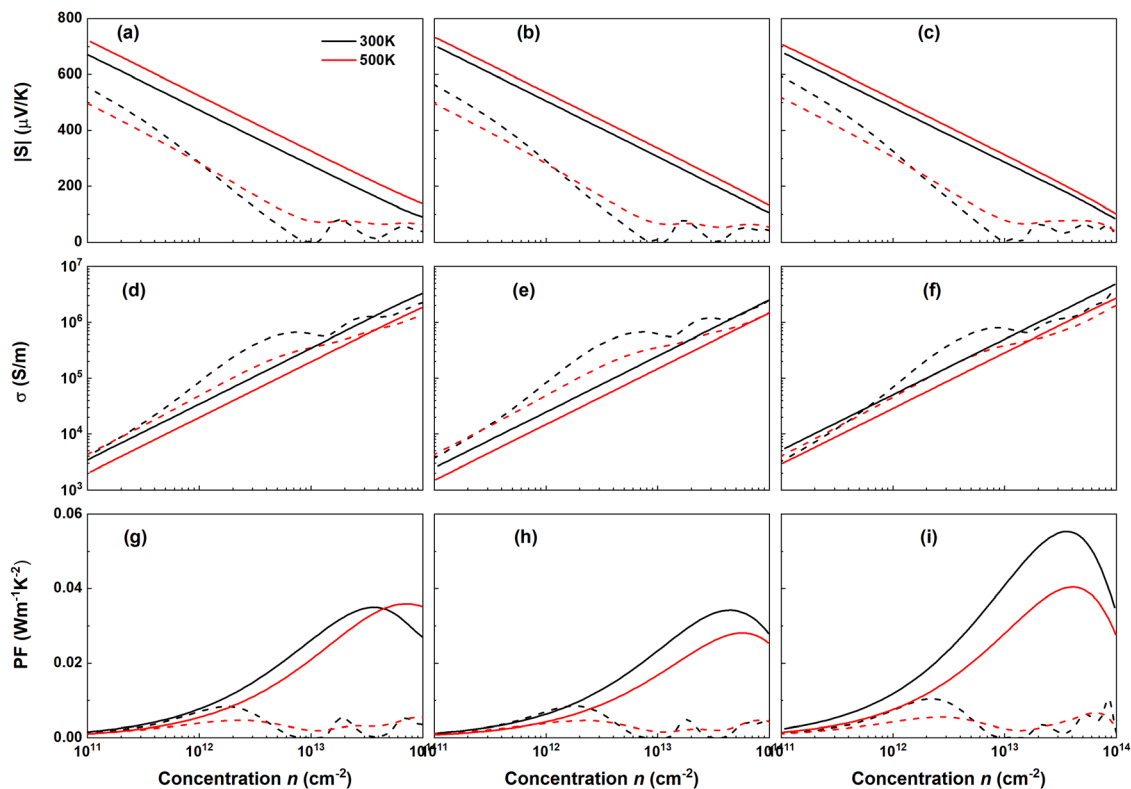


Fig. 5 Concentration  $n$  dependencies of  $|S|$ ,  $\sigma$ , and PF at 300 and 500 K for the three monolayers. The solid lines indicate the data of p-type doping, while the dashed lines represent n-type doping. And the 1st, 2nd and 3rd columns correspond to the Janus  $\alpha$ -STe<sub>2</sub>,  $\alpha$ -SeTe<sub>2</sub>, and pristine  $\alpha$ -Te monolayers, respectively.

The calculated  $\kappa_e$  values of the three monolayers at 300 and 500 K are displayed in Fig. 6. Since  $\kappa_e$  and  $\sigma$  are linearly related,  $\kappa_e$  shows similar dependencies on  $n$  and  $m^*$ .  $\kappa_e$  is very

small when  $n$  is lower than  $10^{13} \text{ cm}^{-2}$ , whereas it increases sharply and exceeds  $15 \text{ W m}^{-1} \text{ K}^{-1}$  at  $10^{14} \text{ cm}^{-2}$ . On the whole,  $\kappa_e$  is much larger for n-type doping than for p-type doping

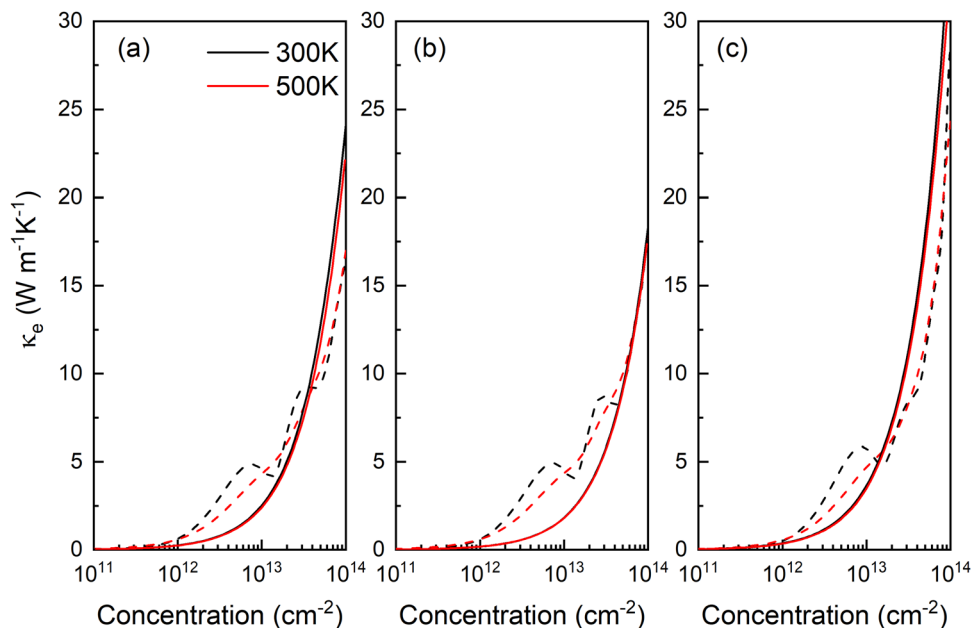


Fig. 6 Electronic thermal conductivity  $\kappa_e$  of (a)  $\alpha$ -STe<sub>2</sub>, (b)  $\alpha$ -SeTe<sub>2</sub>, and (c)  $\alpha$ -Te monolayers at 300 and 500 K. Solid lines indicate  $\kappa_e$  of p-type doping, while dashed lines indicate the ones of n-type doping.

when  $n$  is lower than  $10^{13} \text{ cm}^{-2}$ , as  $m^*$  of the electrons is lower than that of the holes. Combined with lower PF, the  $ZT$  value of n-type doping should be much smaller than that of p-type doping. As the  $m^*$  of a hole in the  $\alpha$ -Te monolayer is the lowest among the three monolayers,  $\kappa_e$  of the  $\alpha$ -Te monolayer is the largest. For instance,  $\kappa_e$  values are 1.30, 0.89, and  $1.82 \text{ Wm}^{-1} \text{ K}^{-1}$  for p-type doped  $\alpha$ -STe<sub>2</sub>,  $\alpha$ -SeTe<sub>2</sub>, and  $\alpha$ -Te monolayers, respectively, at 300 K,  $5 \times 10^{12} \text{ cm}^{-2}$ . It is also found that  $\kappa_e$  is independent of  $T$  approximately.

The  $\kappa_L$  values of full solution for the  $\alpha$ -STe<sub>2</sub>,  $\alpha$ -SeTe<sub>2</sub>, and  $\alpha$ -Te monolayers are calculated, as shown in Fig. 7. For comparison, the values obtained by the relaxation time approximation (RTA) approach are also displayed. To calculate the  $\kappa_L$  of 2D materials, an effective thickness is required, which can be defined as the summation of the buckling height  $h$  and the van der Waals radii of the atoms of the outer layer.<sup>70</sup> The effective thicknesses are 7.20, 7.45, and 7.79 Å for  $\alpha$ -STe<sub>2</sub>,  $\alpha$ -SeTe<sub>2</sub>, and  $\alpha$ -Te monolayers, respectively. The ultralow values of  $\kappa_L$  obtained from the full solution (RTA) are 1.18 (0.39), 0.73 (0.32), and  $3.01$  ( $1.12$ )  $\text{Wm}^{-1} \text{ K}^{-1}$  at 300 K, respectively. Although the RTA approach underestimates  $\kappa_L$  significantly, it is particularly useful for a quite big sample size and slow heating experimental conditions.<sup>71–73</sup> However, our discussion is based on the results of full solution, as our work focuses more on the theoretical research. The values are in agreement with those of previous studies.<sup>33,59</sup> The  $\kappa_L$  values are much lower than those of many 2D monolayers, such as graphene ( $3716 \text{ Wm}^{-1} \text{ K}^{-1}$ ),<sup>74,75</sup> silicene ( $28.3 \text{ Wm}^{-1} \text{ K}^{-1}$ ),<sup>74,75</sup> blue phosphorene ( $106.6 \text{ Wm}^{-1} \text{ K}^{-1}$ ),<sup>74</sup> and MoS<sub>2</sub> monolayers ( $87.6 \text{ Wm}^{-1} \text{ K}^{-1}$ ).<sup>76</sup> An ultralow  $\kappa_L$  value generally corresponds to high TE efficiency. It is also found that  $\kappa_L$  values are close to  $\kappa_e$  at  $5 \times 10^{12} \text{ cm}^{-2}$  and room temperature. As is well known,  $\kappa_L$  usually dominates the TE performance, while the effect of  $\kappa_e$  can be neglected. However,  $\kappa_e$  is comparable to  $\kappa_L$  here, as  $\kappa_L$  is quite low (around  $1 \text{ Wm}^{-1} \text{ K}^{-1}$ ). It implies that  $\kappa_e$  may also play

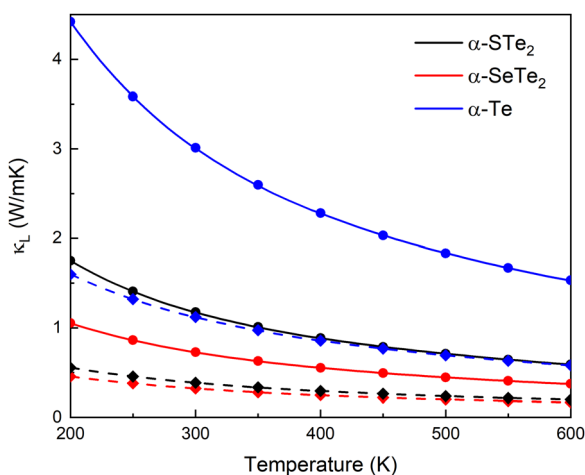


Fig. 7 Temperature dependence of lattice thermal conductivity  $\kappa_L$  for  $\alpha$ -STe<sub>2</sub>,  $\alpha$ -SeTe<sub>2</sub>, and  $\alpha$ -Te monolayers. The circles represent the values of  $\kappa_L$  obtained from the full solution, while the solid lines indicate the corresponding  $1/T$  fitting. For comparison, the diamonds and dashed lines represent the data of the RTA approach.

Table 4 Normalized contribution of each phonon mode to the total  $\kappa_L$  for the three 2D materials. The mode number is given in the ascending order of phonon frequency around the  $\Gamma$  point. Modes 1 to 3 belongs to the acoustic mode, and the others belong to the optical mode

Mode	1	2	3	4	5	6	7	8	9
$\alpha$ -STe <sub>2</sub>	0.267	0.260	0.148	0.073	0.118	0.016	0.011	0.095	0.012
$\alpha$ -SeTe <sub>2</sub>	0.145	0.140	0.137	0.076	0.027	0.020	0.039	0.324	0.092
$\alpha$ -Te	0.156	0.230	0.192	0.021	0.005	0.031	0.016	0.262	0.087

an important role in TE performance. Furthermore, the curves of  $\kappa_L$  well satisfy the relationship  $\kappa_L \propto 1/T$ , indicating the dominant Umklapp process. At 500 K,  $\kappa_L$  values are reduced to 0.71, 0.45, and  $1.83 \text{ Wm}^{-1} \text{ K}^{-1}$  for  $\alpha$ -STe<sub>2</sub>,  $\alpha$ -SeTe<sub>2</sub>, and  $\alpha$ -Te monolayers, respectively.

Furthermore, the normalized contribution of each mode to total  $\kappa_L$  at 300 K is also investigated, as listed in Table 4. It is found that the acoustic modes contribute 67.5%, 42.1% and 57.8% to the total  $\kappa_L$  for  $\alpha$ -STe<sub>2</sub>,  $\alpha$ -SeTe<sub>2</sub>, and  $\alpha$ -Te monolayers, respectively. In other words, the contributions of optical modes are 32.5%, 57.9%, and 42.2%, respectively. The contributions of optical phonons are quite significant, much higher than those of many other 2D materials, such as graphene,<sup>77</sup> MoS<sub>2</sub> monolayer,<sup>76</sup> and stanene.<sup>78</sup>

Debye temperature  $\Theta_D$  is related closely to the thermal properties of materials, and can be expressed as  $\Theta_D = h\omega_{\max}/k_B$ , where  $h$  and  $\omega_{\max}$  are the Planck constant and the maximum of acoustic phonon frequency, respectively.<sup>79</sup> They are 131, 123, and 105 K for  $\alpha$ -STe<sub>2</sub>,  $\alpha$ -SeTe<sub>2</sub>, and  $\alpha$ -Te monolayers, respectively. Usually, high  $\Theta_D$  indicates strong harmonic properties, and hence high  $\kappa_L$ . However,  $\alpha$ -Te possesses the lowest  $\Theta_D$  and the highest  $\kappa_L$  among the three monolayers. The abnormal case of  $\kappa_L$  stems from  $\Theta_D$  measures the harmonic properties only, whereas  $\kappa_L$  is determined by both harmonic and anharmonic properties. To unveil the underlying physical mechanisms, the total phase space for three-phonon processes  $P_3$  and Grüneisen parameters  $\gamma$  are calculated, as displayed in Fig. 8. Note that  $P_3$  is the direct measure of the number of scattering processes available to each phonon, depending on the phonon dispersions only.<sup>75,80</sup> Based on Fig. 8(a)–(c) the dispersions of  $P_3$  are similar to each other, indicating that they are not the main reason for the abnormal  $\kappa_L$  of the monolayers. On the other hand, the Grüneisen parameter  $\gamma$  is the measure of the anharmonic interactions, and a high value of  $\gamma$  leads to a low  $\kappa_L$ .<sup>75,81</sup> Overall,  $|\gamma|$  of  $\alpha$ -Te is smaller than those of  $\alpha$ -STe<sub>2</sub> and  $\alpha$ -SeTe<sub>2</sub>, as shown in Fig. 8(d)–(f), especially for the TA phonon branch. Specifically, the maximum value of  $|\gamma|$  is only 2.6 for  $\alpha$ -Te, while it can reach 20 for  $\alpha$ -STe<sub>2</sub> and  $\alpha$ -SeTe<sub>2</sub>. The phonon relaxation times  $\tau_{\text{ph}}$  of the three monolayers are also exhibited in Fig. 8(g)–(i).  $\tau_{\text{ph}}$  of  $\alpha$ -STe<sub>2</sub> and  $\alpha$ -SeTe<sub>2</sub> is significantly lower than that of  $\alpha$ -Te, resulting from the much higher  $|\gamma|$ . It is concluded that due to the breaking of the inversion symmetry with respect to the central plane of the structure, the Janus  $\alpha$ -STe<sub>2</sub> and  $\alpha$ -SeTe<sub>2</sub> monolayers introduce much stronger anharmonicity, leading to an abnormally lower  $\kappa_L$  than that of  $\alpha$ -Te.<sup>45</sup>

Based on the electronic and thermal transport coefficients, the  $ZT$  values of the three monolayers are estimated and shown

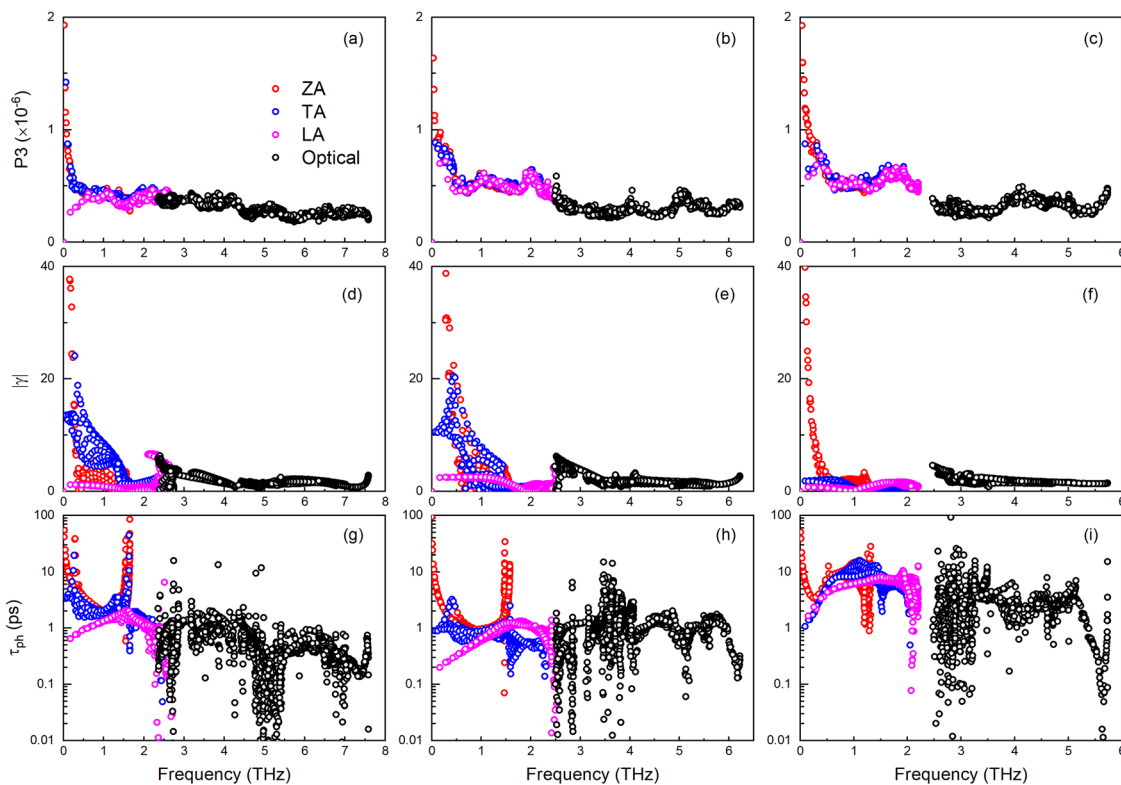


Fig. 8 (a–c) Total phase space for three-phonon processes  $P_3$ , (d–f) absolute value of Grüneisen parameters  $|\gamma|$ , and (g–i) phonon relaxation time  $\tau_{\text{ph}}$  for the three monolayers. Note that the 1st, 2nd and 3rd columns correspond to the Janus  $\alpha$ -STe<sub>2</sub>,  $\alpha$ -SeTe<sub>2</sub> and  $\alpha$ -Te monolayers, respectively.

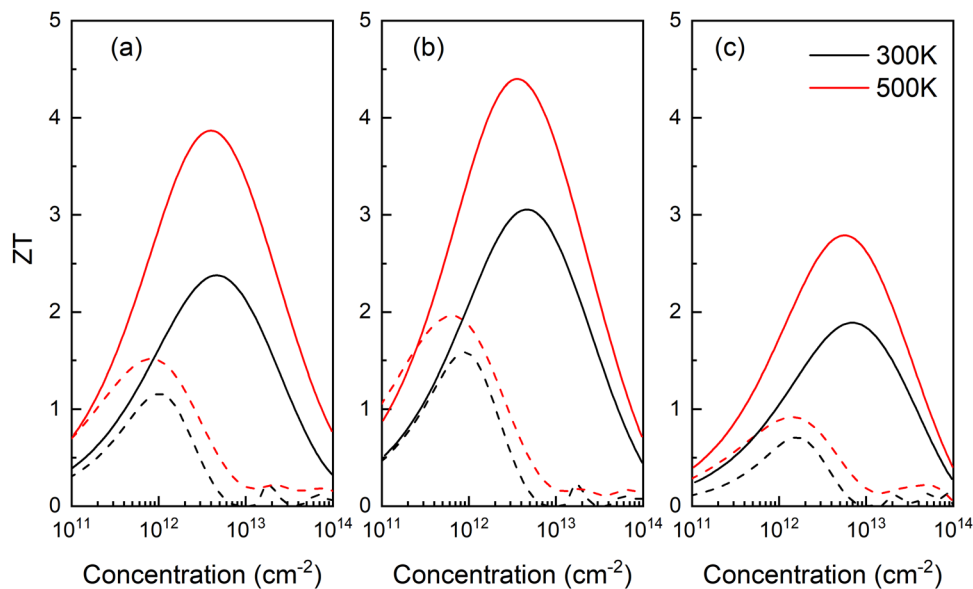


Fig. 9 Figure of merit  $ZT$  for (a) Janus  $\alpha$ -STe<sub>2</sub>, (b)  $\alpha$ -SeTe<sub>2</sub> and (c) pristine  $\alpha$ -Te monolayers, respectively. The solid lines indicate the values of p-type doped monolayers, while the dashed lines represent the n-type doping.

in Fig. 9. They possess ultrahigh  $ZT$  values for p-type doping. At 500 K, the three monolayers have the maximum  $ZT$  values of 3.9, 4.4, and 2.8 for  $\alpha$ -STe<sub>2</sub>,  $\alpha$ -SeTe<sub>2</sub> and  $\alpha$ -Te monolayers, respectively, corresponding to the values of  $n$  of  $4 \times 10^{12}$ ,  $4 \times 10^{12}$ , and  $5 \times 10^{12} \text{ cm}^{-2}$ . The  $\alpha$ -SeTe<sub>2</sub> monolayer has the

highest  $ZT$  value as it has the lowest  $\kappa_e$  and  $\kappa_L$  ( $0.67$  and  $0.45 \text{ W m}^{-1} \text{ K}^{-1}$ ) at 500 K, while the ones of pristine  $\alpha$ -Te are the highest ( $1.95$  and  $1.83 \text{ W m}^{-1} \text{ K}^{-1}$ ). Therefore, the much lower  $\kappa_L$  of the  $\alpha$ -SeTe<sub>2</sub> monolayer mainly leads to a much higher  $ZT$  value than that of  $\alpha$ -Te. For the three monolayers



studied here, higher PF does not always lead to higher  $ZT$ . For example,  $\alpha$ -Te has the highest PF ( $0.040 \text{ Wm}^{-1} \text{ K}^{-2}$  at 500 K) and the lowest  $ZT$ , whereas  $\alpha$ -SeTe<sub>2</sub> possesses the lowest PF ( $0.028 \text{ Wm}^{-1} \text{ K}^{-2}$  at 500 K) and the highest  $ZT$ . Thus, it can be concluded that Janus structures can enhance TE performance remarkably as they have much lower thermal conductivity, including  $\kappa_e$  and  $\kappa_L$ . Additionally, it is also found that  $\kappa_e$  is a little higher than  $\kappa_L$  in the three monolayers, and can affect  $ZT$  significantly. It confirms that  $\kappa_e$  cannot be neglected for the TE materials with quite low  $\kappa_L$ . Even at room temperature, these monolayers also have large  $ZT$  values, which reach 2.4, 3.1, and 1.9 for  $\alpha$ -STe<sub>2</sub>,  $\alpha$ -SeTe<sub>2</sub> and  $\alpha$ -Te, respectively. Thus, these materials are especially suitable for TE devices in daily life. On the other hand, the  $ZT$  values are much lower for n-type doping than for p-type, because of the smaller PF values and larger  $\kappa_e$  values for n-type doping.

## Conclusions

In summary, the electronic, thermal transport properties and TE performances of Janus  $\alpha$ -STe<sub>2</sub> and  $\alpha$ -SeTe<sub>2</sub> monolayers are investigated using first-principles calculations combined with semiclassical Boltzmann theory. For comparison, the TE properties of the pristine  $\alpha$ -Te monolayer are also studied. The electronic band structures, effective masses, and carrier relaxation times are similar to each other. Janus structures have different VBM, larger band gaps, and reduced PF values, compared with the pristine  $\alpha$ -Te. However, the breaking of the inversion symmetry greatly reduces the  $\kappa_L$  by enhancing the phonon anharmonicity in the Janus  $\alpha$ -STe<sub>2</sub> and  $\alpha$ -SeTe<sub>2</sub> monolayers. Furthermore, Janus monolayers also possess smaller  $\kappa_e$ . Note here that  $\kappa_e$  plays an important role in  $ZT$  as it can be comparable with  $\kappa_L$ . Thus, the  $ZT$  values of the Janus  $\alpha$ -STe<sub>2</sub> and  $\alpha$ -SeTe<sub>2</sub> monolayers are much higher than those of the pristine  $\alpha$ -Te monolayer. Particularly, the  $ZT$  value of the Janus  $\alpha$ -SeTe<sub>2</sub> monolayer is as high as about 4.4 at 500 K. Our work indicates that Janus  $\alpha$ -SeTe<sub>2</sub> and  $\alpha$ -STe<sub>2</sub> are promising thermoelectric materials. Furthermore, it also suggests that using a Janus structure is an effective method to reduce  $\kappa_L$  and enhance  $ZT$ .

## Conflicts of interest

There are no conflicts to declare.

## Acknowledgements

This work was supported by the National Natural Science Foundation of China (no. 11974100, 12104356, and 61874160) and the Program for Innovative Research Team (in Science and Technology) in the University of Henan Province (22IRTSTHN012). Z. Gao acknowledges the support from the China Postdoctoral Science Foundation (no. 2022M712552) and the Fundamental Research Funds for the Central Universities.

We also acknowledge the support from the HPC Platform, Xi'an Jiaotong University.

## References

- W. Liu, X. Yan, G. Chen and Z. Ren, *Nano Energy*, 2012, **1**, 42–56.
- J. Yang, L. Xi, W. Qiu, L. Wu, X. Shi, L. Chen, J. Yang, W. Zhang, C. Uher and D. J. Singh, *npj Comput. Mater.*, 2016, **2**, 15015.
- T. Zhu, Y. Liu, C. Fu, J. P. Heremans, J. G. Snyder and X. Zhao, *Adv. Mater.*, 2017, **29**, 1605884.
- K. Biswas, J. He, I. D. Blum, C.-I. Wu, T. P. Hogan, D. N. Seidman, V. P. Dravid and M. G. Kanatzidis, *Nature*, 2012, **489**, 414–418.
- C. M. Jaworski, B. Wiendlocha, V. Jovic and J. P. Heremans, *Energy Environ. Sci.*, 2011, **4**, 4155–4162.
- X. Su, N. Zhao, S. Hao, C. C. Stoumpos, M. Liu, H. Chen, H. Xie, Q. Zhang, C. Wolverton, X. Tang and M. G. Kanatzidis, *Adv. Funct. Mater.*, 2019, **29**, 1806534.
- C. Xiao, K. Li, J. Zhang, W. Tong, Y. Liu, Z. Li, P. Huang, B. Pan, H. Su and Y. Xie, *Mater. Horiz.*, 2014, **1**, 81–86.
- N. Wang, M. Li, H. Xiao, Z. Gao, Z. Liu, X. Zu, S. Li and L. Qiao, *npj Comput. Mater.*, 2021, **7**, 18.
- M. S. Dresselhaus, G. Chen, M. Y. Tang, R. G. Yang, H. Lee, D. Z. Wang, Z. F. Ren, J. P. Fleurial and P. Gogna, *Adv. Mater.*, 2007, **19**, 1043–1053.
- R. Venkatasubramanian, E. Siivola, T. Colpitts and B. O'Quinn, *Nature*, 2001, **413**, 597–602.
- Z. Gao, G. Liu and J. Ren, *ACS Appl. Mater. Interfaces*, 2018, **10**, 40702–40709.
- Z. Gao and J. S. Wang, *ACS Appl. Mater. Interfaces*, 2020, **12**, 14298–14307.
- K. S. Novoselov, A. K. Geim, S. V. Morozov, D. Jiang, Y. Zhang, S. V. Dubonos, I. V. Grigorieva and A. A. Firsov, *Science*, 2004, **306**, 666–669.
- S. Stankovich, D. A. Dikin, R. D. Piner, K. A. Kohlhaas, A. Kleinhammes, Y. Jia, Y. Wu, S. T. Nguyen and R. S. Ruoff, *Carbon*, 2007, **45**, 1558–1565.
- A. H. C. Neto and K. Novoselov, *Rep. Prog. Phys.*, 2011, **74**, 082501.
- K. F. Mak, C. Lee, J. Hone, J. Shan and T. F. Heinz, *Phys. Rev. Lett.*, 2010, **105**, 136805.
- A. Splendiani, L. Sun, Y. Zhang, T. Li, J. Kim, C.-Y. Chim, G. Galli and F. Wang, *Nano Lett.*, 2010, **10**, 1271–1275.
- L. Li, Y. Yu, G. J. Ye, Q. Ge, X. Ou, H. Wu, D. Feng, X. H. Chen and Y. Zhang, *Nat. Nanotechnol.*, 2014, **9**, 372–377.
- C. Zhi, Y. Bando, C. Tang, H. Kuwahara and D. Golberg, *Adv. Mater.*, 2009, **21**, 2889–2893.
- S. Z. Butler, S. M. Hollen, L. Cao, Y. Cui, J. A. Gupta, H. R. Gutiérrez, T. F. Heinz, S. S. Hong, J. Huang, A. F. Ismach, E. Johnston-Halperin, M. Kuno, V. V. Plashnitsa, R. D. Robinson, R. S. Ruoff, S. Salahuddin, J. Shan, L. Shi, M. G. Spencer, M. Terrones, W. Windl and J. E. Goldberger, *ACS Nano*, 2013, **7**, 2898–2926.

- 21 M. Xu, T. Liang, M. Shi and H. Chen, *Chem. Rev.*, 2013, **113**, 3766–3798.
- 22 Z. Zhu, X. Cai, S. Yi, J. Chen, Y. Dai, C. Niu, Z. Guo, M. Xie, F. Liu, J. H. Cho, Y. Jia and Z. Zhang, *Phys. Rev. Lett.*, 2017, **119**, 106101.
- 23 J. Chen, Y. Dai, Y. Ma, X. Dai, W. Ho and M. Xie, *Nanoscale*, 2017, **9**, 15945–15948.
- 24 Y. Wang, G. Qiu, R. Wang, S. Huang, Q. Wang, Y. Liu, Y. Du, W. A. Goddard, M. J. Kim, X. Xu, P. D. Ye and W. Wu, *Nat. Electron.*, 2018, **1**, 228–236.
- 25 X. Huang, J. Guan, Z. Lin, B. Liu, S. Xing, W. Wang and J. Guo, *Nano Lett.*, 2017, **17**, 4619–4623.
- 26 J. Qin, G. Qiu, J. Jian, H. Zhou, L. Yang, A. Charnas, D. Y. Zemlyanov, C.-Y. Xu, X. Xu, W. Wu, H. Wang and P. D. Ye, *ACS Nano*, 2017, **11**, 10222–10229.
- 27 A. Apte, E. Bianco, A. Krishnamoorthy, S. Yazdi, R. Rao, N. Glavin, H. Kumazoe, V. Varshney, A. Roy, F. Shimojo, E. Ringe, R. K. Kalia, A. Nakano, C. S. Tiwary, P. Vashishta, V. Kochat and P. M. Ajayan, *2D Mater.*, 2018, **6**, 015013.
- 28 S. Yang, B. Chen, Y. Qin, Y. Zhou, L. Liu, M. Durso, H. Zhuang, Y. Shen and S. Tongay, *Phys. Rev. Lett.*, 2018, **2**, 104002.
- 29 D. Wang, A. Yang, T. Lan, C. Fan, J. Pan, Z. Liu, J. Chu, H. Yuan, X. Wang, M. Rong and N. Koratkar, *J. Mater. Chem. A*, 2019, **7**, 26326–26333.
- 30 Y. Liu, W. Wu and W. A. Goddard, *J. Am. Chem. Soc.*, 2018, **140**, 550–553.
- 31 J. Qiao, Y. Pan, F. Yang, C. Wang, Y. Chai and W. Ji, *Sci. Bull.*, 2018, **63**, 159–168.
- 32 S. Sharma, N. Singh and U. Schwingenschlögl, *ACS Appl. Energy Mater.*, 2018, **1**, 1950–1954.
- 33 J. Ma, F. Meng, J. He, Y. Jia and W. Li, *ACS Appl. Mater. Interfaces*, 2020, **12**, 43901–43910.
- 34 Y. C. Cheng, Z. Y. Zhu, M. Tahir and U. Schwingenschlögl, *EPL*, 2013, **102**, 57001.
- 35 A.-Y. Lu, H. Zhu, J. Xiao, C.-P. Chuu, Y. Han, M.-H. Chiu, C.-C. Cheng, C.-W. Yang, K.-H. Wei, Y. Yang, Y. Wang, D. Sokaras, D. Nordlund, P. Yang, D. A. Muller, M.-Y. Chou, X. Zhang and L.-J. Li, *Nat. Nanotechnol.*, 2017, **12**, 744–749.
- 36 J. Zhang, S. Jia, I. Kholmanov, L. Dong, D. Er, W. Chen, H. Guo, Z. Jin, V. B. Shenoy, L. Shi and J. Lou, *ACS Nano*, 2017, **11**, 8192–8198.
- 37 R. Li, Y. Cheng and W. Huang, *Small*, 2018, **14**, 1802091.
- 38 X. Yang, D. Singh, Z. Xu, Z. Wang and R. Ahuja, *J. Mater. Chem. C*, 2019, **7**, 12312–12320.
- 39 X. Yang, A. Banerjee and R. Ahuja, *ChemCatChem*, 2020, **12**, 6013–6023.
- 40 A. Rawat, M. K. Mohanta, N. Jena, Dimple, R. Ahammed and A. D. Sarkar, *J. Phys. Chem. C*, 2020, **124**, 10385–10397.
- 41 X. Yang, D. Singh, Z. Xu and R. Ahuja, *New J. Chem.*, 2020, **44**, 7932–7940.
- 42 S.-D. Guo, *Phys. Chem. Chem. Phys.*, 2018, **20**, 7236–7242.
- 43 S.-D. Guo, X.-S. Guo and Y. Deng, *J. Appl. Phys.*, 2019, **126**, 154301.
- 44 L. Cao, Y. S. Ang, Q. Wu and L. K. Ang, *Appl. Phys. Lett.*, 2019, **115**, 241601.
- 45 R. Gupta, B. Dongre, C. Bera and J. Carrete, *J. Phys. Chem. C*, 2020, **124**, 17476–17484.
- 46 A. Patel, D. Singh, Y. Sonvane, P. B. Thakor and R. Ahuja, *ACS Appl. Mater. Interfaces*, 2020, **12**, 46212–46219.
- 47 G. Kresse and D. Joubert, *Phys. Rev. B: Condens. Matter Mater. Phys.*, 1999, **59**, 1758–1775.
- 48 G. Kresse and J. Furthmüller, *Phys. Rev. B: Condens. Matter Mater. Phys.*, 1996, **54**, 11169–11186.
- 49 J. P. Perdew, K. Burke and M. Ernzerhof, *Phys. Rev. Lett.*, 1996, **77**, 3865–3868.
- 50 H. J. Monkhorst and J. D. Pack, *Phys. Rev. B: Solid State*, 1976, **13**, 5188–5192.
- 51 S. Grimme, *J. Comput. Chem.*, 2006, **27**, 1787–1799.
- 52 J. Heyd, G. E. Scuseria and M. Ernzerhof, *J. Chem. Phys.*, 2003, **118**, 8207–8215.
- 53 W. G. Hoover, *Phys. Rev. A: At., Mol., Opt. Phys.*, 1985, **31**, 1695–1697.
- 54 S. Nosé, *Mol. Phys.*, 1986, **57**, 187–191.
- 55 G. K. H. Madsen, J. Carrete and M. J. Verstraete, *Comput. Phys. Commun.*, 2018, **231**, 140–145.
- 56 A. Togo and I. Tanaka, *Scr. Mater.*, 2015, **108**, 1–5.
- 57 J. Carrete, B. Vermeersch, A. Katre, A. van Roekeghem, T. Wang, G. K. H. Madsen and N. Mingo, *Comput. Phys. Commun.*, 2017, **220**, 351–362.
- 58 V. B. Anzin, M. I. Eremets, Y. V. Kosichkin, A. I. Nadezhdinskii and A. M. Shirokov, *Phys. Status Solidi A*, 1977, **42**, 385–390.
- 59 J. Singh, M. Jakhar and A. Kumar, *Nanotechnology*, 2022, **33**, 215405.
- 60 H. Usui, K. Suzuki, K. Kuroki, S. Nakano, K. Kudo and M. Nohara, *Phys. Rev. B: Condens. Matter Mater. Phys.*, 2013, **88**, 075140.
- 61 K. Kuroki and R. Arita, *J. Phys. Soc. Jpn.*, 2007, **76**, 083707.
- 62 H. Usui and K. Kuroki, *J. Appl. Phys.*, 2017, **121**, 165101.
- 63 Y. Chen, J. Liu, J. Yu, Y. Guo and Q. Sun, *Phys. Chem. Chem. Phys.*, 2019, **21**, 1207–1216.
- 64 M. Cutler, J. F. Leavy and R. L. Fitzpatrick, *Phys. Rev.*, 1964, **133**, A1143–A1152.
- 65 G. D. Mahan and J. O. Sofo, *Proc. Natl. Acad. Sci. U. S. A.*, 1996, **93**, 7436–7439.
- 66 J. Qiao, X. Kong, Z.-X. Hu, F. Yang and W. Ji, *Nat. Commun.*, 2014, **5**, 4475.
- 67 G. J. Snyder and E. S. Toberer, *Nat. Mater.*, 2008, **7**, 105–114.
- 68 F. Q. Wang, S. Zhang, J. Yu and Q. Wang, *Nanoscale*, 2015, **7**, 15962–15970.
- 69 G. K. H. Madsen and D. J. Singh, *Comput. Phys. Commun.*, 2006, **175**, 67–71.
- 70 X. Wu, V. Varshney, J. Lee, Y. Pang, A. K. Roy and T. Luo, *Chem. Phys. Lett.*, 2017, **669**, 233–237.
- 71 P. Torres, F. X. Alvarez, X. Cartoixa and R. Rurali, *2D Mater.*, 2019, **6**, 035002.
- 72 B. Lv, X. Hu, N. Wang, J. Song, X. Liu and Z. Gao, *Appl. Surf. Sci.*, 2021, **559**, 149463.
- 73 N. Wang, H. Gong, Z. Sun, C. Shen, B. Li, H. Xiao, X. Zu, D. Tang, Z. Yin, X. Wu, H. Zhang and L. Qiao, *ACS Appl. Energy Mater.*, 2021, **4**, 12163–12176.

- 74 B. Peng, D. Zhang, H. Zhang, H. Shao, G. Ni, Y. Zhu and H. Zhu, *Nanoscale*, 2017, **9**, 7397–7407.
- 75 B. Peng, H. Zhang, H. Shao, Y. Xu, G. Ni, R. Zhang and H. Zhu, *Phys. Rev. B*, 2016, **94**, 245420.
- 76 B. Peng, H. Zhang, H. Shao, Y. Xu, X. Zhang and H. Zhu, *Ann. Phys.*, 2016, **528**, 504–511.
- 77 L. Lindsay, W. Li, J. Carrete, N. Mingo, D. A. Broido and T. L. Reinecke, *Phys. Rev. B: Condens. Matter Mater. Phys.*, 2014, **89**, 155426.
- 78 B. Peng, H. Zhang, H. Shao, Y. Xu, X. Zhang and H. Zhu, *Sci. Rep.*, 2016, **6**, 20225.
- 79 L.-D. Zhao, S.-H. Lo, Y. Zhang, H. Sun, G. Tan, C. Uher, C. Wolverton, V. P. Dravid and M. G. Kanatzidis, *Nature*, 2014, **508**, 373–377.
- 80 W. Li and N. Mingo, *Phys. Rev. B: Condens. Matter Mater. Phys.*, 2015, **91**, 144304.
- 81 Z. Gao, F. Tao and J. Ren, *Nanoscale*, 2018, **10**, 12997–13003.